• Accommodates substrates 300x300mm², or roll to roll materials.
• UV broadband exposure with full-field global alignment or multi step quadrant exposure modes.
• Available with manual substrate loading, robotic loading or roll to roll format.
• Stage, alignment and exposure system incorporates field-proven designs
• Resolution of >= 2.0 um in contact or 3.5 um in proximity.
• Alignment Overlay of 1.5 um 3 sigma.